June 15 - 19, 2014
Berlin, Germany

Important Dates

Registration and abstract submission starts: Oct 15, 2013

Abstract submission deadline: Mar 1, 2014

Abstract acceptance notification: Mar 20, 2014

Early registration ends: Apr 15, 2014

Location

The workshop will be located at the Novotel Am Tiergarten, located in the inner city of Berlin, the vibrant capital of Germany, with a lot of sightseeing opportunities nearby.

For details visit http://iwcgt-6.ikz-berlin.de.

Conference Contact

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International Organization
for Crystal Growth
http://www.iocg.org/

GERMANY
JUNE 15 - 19

6th International Workshop on Crystal Growth Technology

IWCGT-6

1st Announcement

BERLIN 2014

Topical Sessions

Advances in bulk crystal growth of semiconductor and photovoltaic materials

Optical and laser crystals

Scintillators, piezo- and magnetoelectrics

Substrates for wide band-gap and oxide semiconductors

Growth control, quality assurance & management of resources

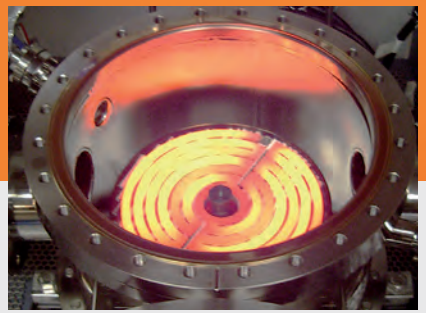
Crystal shaping and layer transfer technologies

Frontiers in crystal growth technology

Panel Discussion

Advancing new growth technologies to industrial application

6th International Workshop on Crystal Growth Technology



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Conference Chairs

Matthias Bickermann, IKZ Berlin, Germany

Chung-Wen Lan, National Taiwan University, Taiwan

Peter G. Schunemann, BAE Systems, USA

Further Information

Visit http://iwcgt-6.ikz-berlin.de

For any questions and to receive further information about the IWCGT-6, send an email to:
iwcgt-6@ikz-berlin.de

Steering Committee

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- Evgenii V. Zharikov, D. Mendeleev University, Moscow, Russia

Scope

This workshop – the sixth of a series initiated by Hans Scheel in 1998 – is devoted to crystal growth technology: industrial production, machining, and equipment. The focus lies on the preparation of bulk and substrate crystals.

The workshop is organized by the Leibniz Institute for Crystal Growth (IKZ) Berlin, Germany, under the auspices of the International Organization for Crystal Growth (IOCG). The previous workshop was attended by more than 170 participants from industry and academia.

The workshop is intended to link science and practice, i.e., R&D and the actual production. The workshop will start with a stimulating panel discussion on how to advance new growth technologies to industrial application.

Its further program consists of invited talks (duration 40 min. each) from international specialists with additional time for discussion and debate.

While the oral presentations will be on invitation only, all participants may present their own results in two evening poster sessions. Meet the experts at IWCGT-6!